

# FLIP CHIP BONDER-A110

Since 1980



FLIP CHIP BONDER - A110



#### High Productivity

- 15,000 UPH (Based on Dry Run)



#### Mass Defect Protection Capability

- Flux, Die Tilt, Ejector Pin Missing, Contamination



#### Precision Bonding Capability

- $\pm 6\mu\text{m}$  @  $3\sigma$



#### Thin Die / Small Die Capability

- Min.  $40\mu\text{m}$  Thickness / Min.  $0.4\text{mm} \times 0.4\text{mm}$



Semiconductor

# FLIP CHIP BONDER A110

## Enhanced Machine Features

### High Productivity

- 15,000 UPH (Based on Dry Run)
- Dual Bonding Head
- Hanmi Special Sequence Profile
- Enhanced Temperature Control System

### Precision Bonding Capability

- $\pm 6\mu\text{m}$  @  $3\sigma$
- Supreme Vision Inspection System
- High Accurate Gantry Structure
- Lower Vibration Control System
- One Casting Body Structure

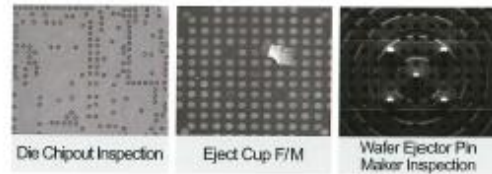
### Mass Defect Protection Capability

- Hanmi Special Flux Vision Inspection System
- Auto Flatness Check System
- Wafer Map Shift Prevent Function
- Foreign Material Detect Inspection System
- Ejector Pin Missing Inspection System
- Chip Out Detect Inspection System
- Multi Reject Mark Reading Capability

### User Friendly & Easy Operation

- Windows Based HMI Screen
- Easy & Quick Conversion
- Easy Maintenance

## "New Technology" Flux Vision Inspection



## Components and Substrates

Wafer	Die Size	0.4mm x 0.4mm
	Die Thickness	0.04mm ~ 3.0mm
	Wafer Size	up to 12"
Substrate	Width	28mm ~ 208mm
	Length	50mm ~ 300mm

## Performance

Productivity	UPH	15,000 (Based on Dry Run)	MTBA	2~5 hours
Accuracy	X-Y Placement	$\pm 6.0\mu\text{m}$ @ $3\sigma$	MTBF	168 hours
	Chip Rotation ( $\theta$ )	$\pm 0.1^\circ$ @ $3\sigma$		
Bonding Head	Bonding Force	1N ~ 20N (Programmable from 1N)	MTTA	3-minutes
Footprint	Dimension (W x D x H)	1,600mm x 1,200mm x 1,500mm	MTTR	30 minutes
	Weight	2,700 kg		



#532-2, Gajwa-Dong, Seo-Gu, Incheon, 404-250, Korea  
TEL. +82-32-571-9100      www.hanmisemi.com